THE INTEGRATED PHOTONICS REVOLUTION

April 11th 2017



OUTLINE

- Introduction to SMART Photonics
- Photonic integration
 - Generic platform
 - Applications and examples
 - MPW service
- Application examples
- Summary

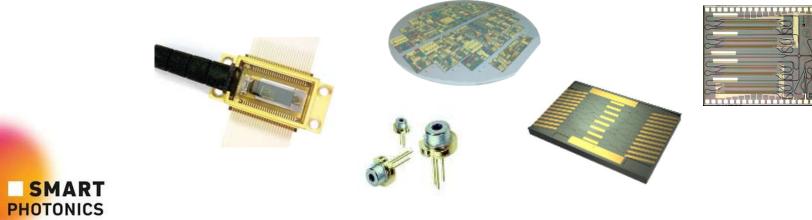


WHO ARE WE?

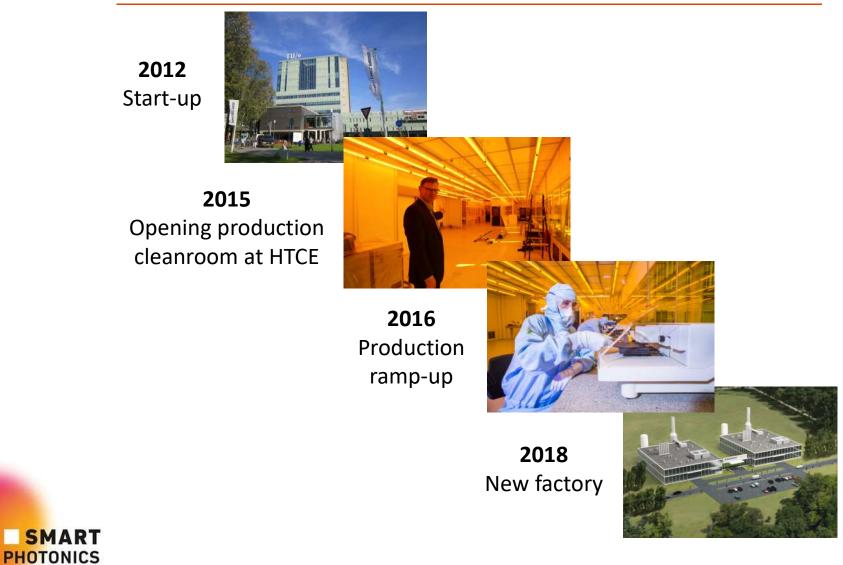
Independent InP Foundry

SMART Photonics B.V. founded in 2012 Independent Foundry for InP based Photonic components





WE ARE MOVING FAST!



5/31/2017 Independent InP Foundry

OUR FACILITIES





- SMART Photonics
 @High Tech Campus
 - 570m² 3" Production cleanroom (Class 1000)
 - Processing and epitaxy

- SMART Photonics
 @NanoLab cleanroom Eindhoven
 - 850m² Fully equipped R&D facility



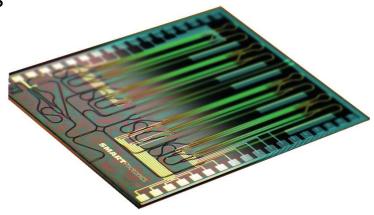
OUR CAPABILITIES

	Epitaxy	Multi-wafer MOVPE reactors for base wafer growth, regrowth and overgrowth
	Lithography	High throughput, high resolution (>100 nm) - DUV scanner 0.7 μm projection litho – I-Line stepper High resolution (<100 nm) – E-beam 0.6 μm contact litho – contact aligner
	Etching	Cassette-based wet etching ICP for single and multi-wafer etching RIE dedicated tools for photoresist, dielectric and polymer etching
	Dielectrics	PECVD for SiO_x and SiN_x
	Metallization	E-beam evaporation Sputtering Plating
	Back-end	Grinding and polishing Scribe and break Optical coatings

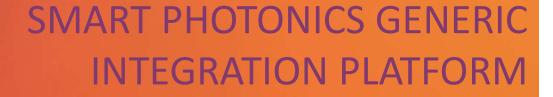


WHAT MAKES US SPECIAL

- People
 - Knowledge and experience in photonics and semiconductor processing
- Capabilities
 - Full process from Epi to coating of facets
 - Unique tools (3" ASML scanner for high resolution litho)
- Proposition
 - Unique PIC technology
 - Buried Hetero DFB process

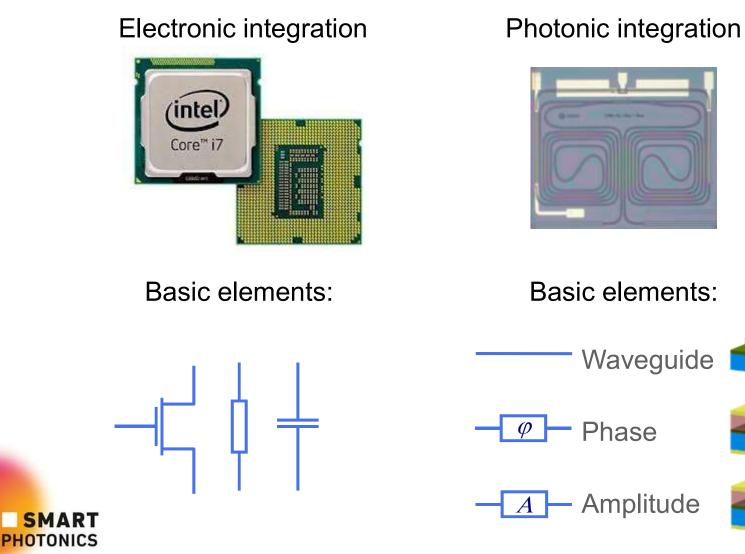




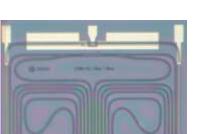




GENERIC INTEGRATION PHILOSOPHY



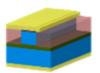
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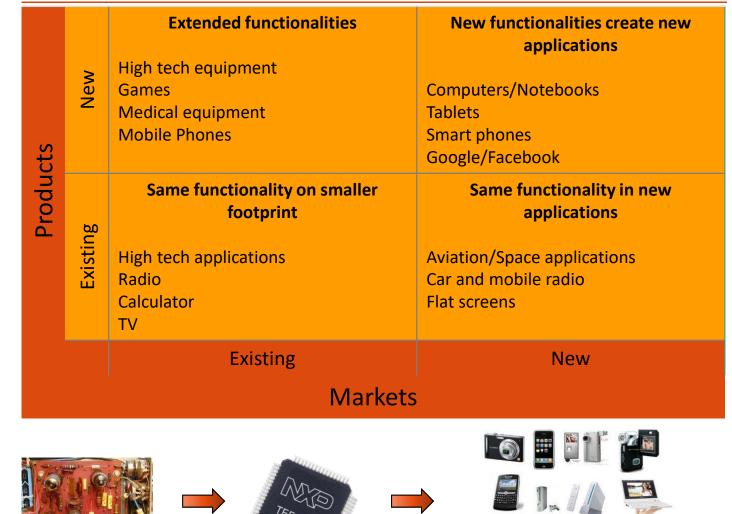








SEMICONDUCTORS



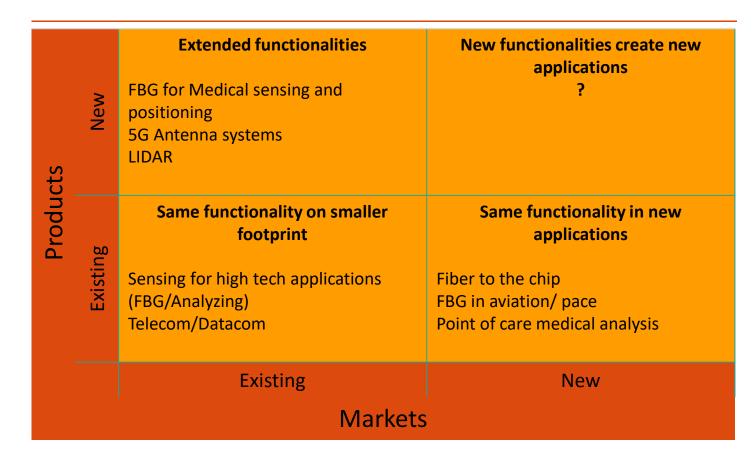








INP PHOTONICS

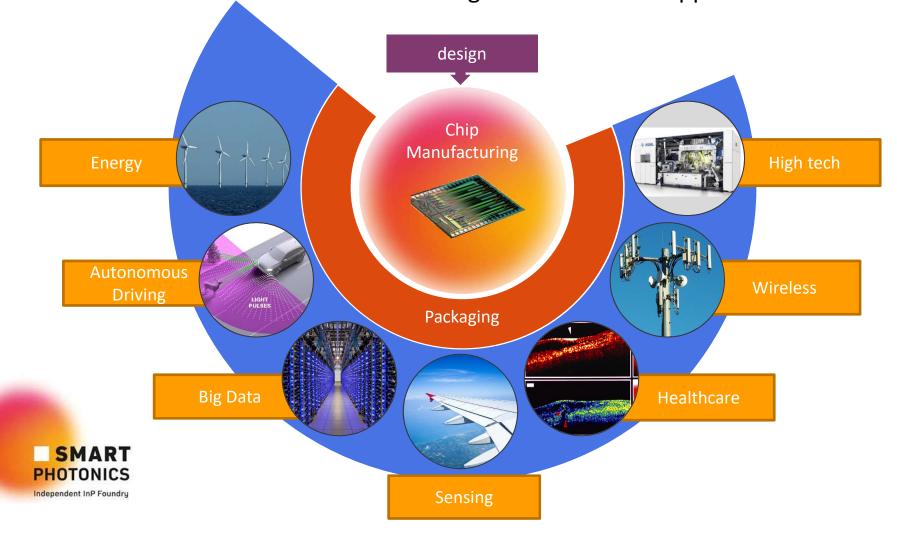




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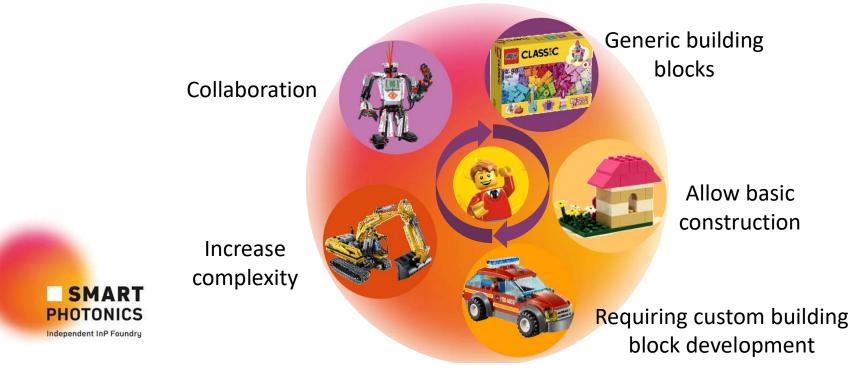
PHOTONIC INTEGRATION MAKES THE DIFFERENCE!

 The SMART Photonics Generic Integration Technology makes the difference enabling a wealth of new applications

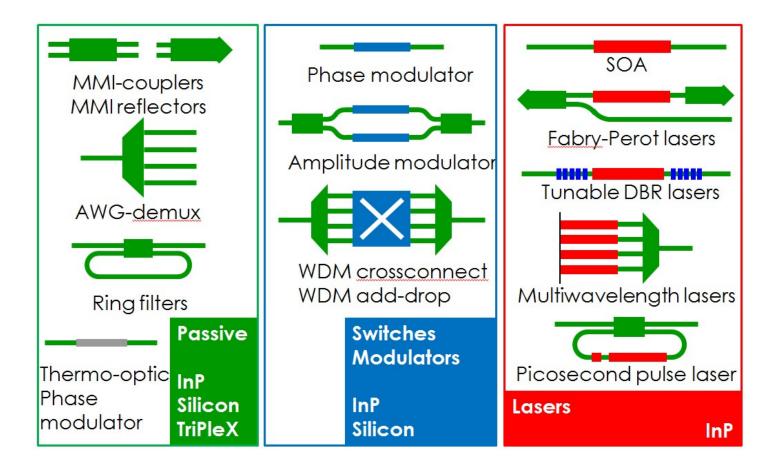


OUR GENERIC INTEGRATION PLATFORM

- Standardized industrial integration process
- Design on *functional level* by using *building block* approach
- Software design kits for fast and accurate design
- Multi-project wafer (MPW) runs for *fast* and *cost efficient* prototyping
- Enables fast up-scaling to high volume manufacturing



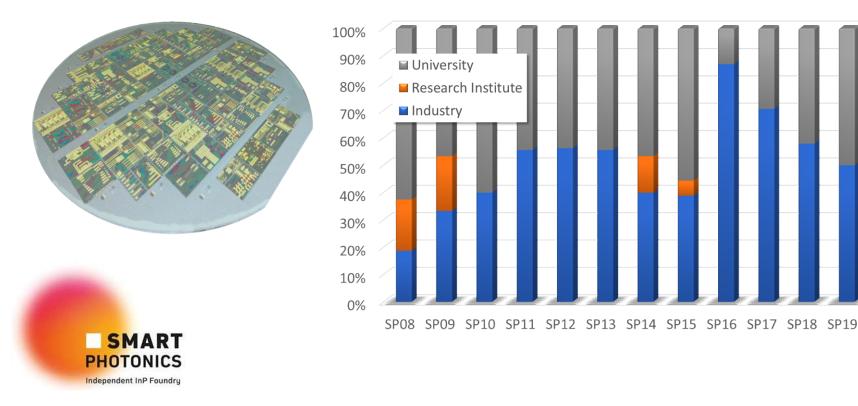
INP PLATFORM CAPABILITIES





OUR MPW SERVICE

- World's first commercial MPW run on InP in July 2013
- MPW run starts every quarter
- Low threshold access to a new technology
- Over 200 designs fabricated!



PDK: BUILDING BLOCK LIBRARY

- Process Design Kit is available
 - For circuit simulation and mask design
 - Design manual and Functional building block description
 - Full layout-aware design flow
 - Access via state of the art software tools











APPLY NOW FOR THE PHOTONDELTA MPW INNOVATION GRANT

- PhotonDelta, in partnership with <u>JePPix</u> and <u>Brainport</u> <u>Development</u>, is now launching a photonics chip incentive scheme. They are reaching out to help global high-tech companies, large and small, design and build nextgeneration photonics chips specific to their business.
- If you're planning to fabricate your photonics chip with companies in Brabant, you may qualify for a PIC Innovation voucher, worth up to € 4,250.00. This is half the cost of an MPW run
- For more information check <u>www.photondelta.eu</u>







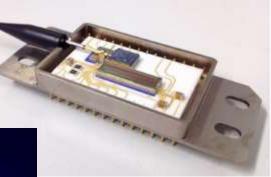
APPLICATION EXAMPLES

YOUR DESIGN OUR SERVICE YOUR FUTURE

EXAMPLE: FBG INTERROGATOR

Distributed temperature and strain measurement with embedded fibers + PIC readouts





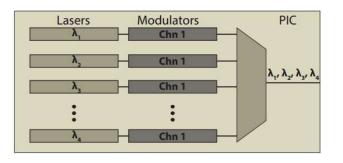
Wider possibilities for structural health monitoring

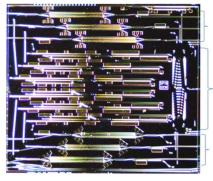




EXAMPLE: 100 GB/S TRANSMITTER

>100 Gb/s transmitter on single chip, fabricated in our powerful MPW platform



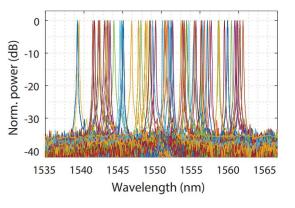


3 x MZM modulator

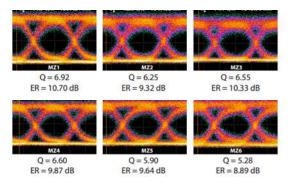
6 x 22 nm tunable laser

3 x MZM modulator

Wavelength tuning



20 Gb/s per channel



W. Yao, COBRA



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SUMMARY

- Generic Integration Process available
 - Transmit and receive platform
- Large range of applications demonstrated
- Commercial, low threshold access to technology via quarterly MPW runs for proof of concept
- Industrial scale, production ready process
- Ready for medium and large volumes



SMART PHOTONICS

Independent InP Foundry